

2006 JOINT USERS MEETING

at Argonne National Laboratory

MAY 1-5, 2006

ADVANCED PHOTON SOURCE

Meeting Highlights

- Four User Facilities
- Washington Update
- 10th Anniversary of APS Operations
- Posters (Student Prizes)
- Vendor Exhibits
- Social Events

Workshops

- Synchrotron science
- 6 entries

FOR NANOSCALE MATERIALS

CENTER

- 6 entries
- Electron microscopy - one entry

Deadlines

- March 15 Abstracts (Posters and Invited Talks)
- March 31 Registration for Non-U.S. Citizens
- April 14 Registration without Late Fee Housing Reservations

www.aps.anl.gov/Users/Meeting/

- Nanoscience
- four entries
- four entries entries
- four entries
- Neutron science
- three entries - three entries
- three entries

Program Chairs

APS: Gene Ice CNM: to be determined EMC: Dean Miller IPNS: Raymond Teller [?]

APS Workshops Beamline controls workshop P. Jemian **High Pressure Workshop** G. Shen **Enviromental Spectromicroscopy** I. McNulty, J. Thieme D. Patterson **Inelastic x-ray science** J. Hill, E Alp Microfocus X-ray diffraction in structural biology S. Ealick

Possible Joint APS/IPNS/Electron Microscopy Center Workshop

Texture and Strain mapping with X-rays, neutrons and electrons D. Haeffner

Possible Joint APS/ CNM workshops

Science opportunities with micro and nano diffraction Q. Shen, B. Larson X-ray imaging (large NA optics, scanning probe, full-field, lensless imaging) In-situ processing and materials growth

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ELECTRON MICROSCO

CHICAGO

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Plenary Sessions • APS Wednesday - May 3

• CNM Monday - May 1